

ABSTRACT

A substrate processing system comprises a plurality of CVD processing units (15a - 15c) and one refrigerator (101). A  
5 supply line (102) for supplying a cooling medium from the refrigerator to the CVD processing units, and a feedback line (103) for feeding the cooling medium back to the refrigerator from the processing units are laid in the system. The cooling  
10 medium from the refrigerator is thus distributively fed to the processing units. Circuits (104a - 104c) are laid out in rod stages (33), objects of temperature control, in the respective processing units. Each circuit is connected to the supply line and to the feedback line. The cooling medium is circulated  
15 stably. When the temperature of the rod stage rises, the cooling medium at a low temperature is taken in the circuit from the supply line to cool the rod stage.